



ap 1752 - DFW
PATENT
30205/38083

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Geun Su Lee et al.

Serial No.: 10/054,532

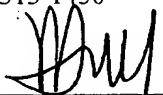
Filed: January 22, 2002

For: Photoresist Monomers, Polymers
Thereof and Photoresist Compositions
Containing the Same

Group Art Unit: 1752

Examiner: Yvette C. Thornton

I hereby certify that this paper and the
documents referred to as enclosed
therewith are being deposited with the
United States Postal Service as first class
mail, postage prepaid, on November 15,
2004, in an envelope addressed to MS
Amendment, Commissioner for Patents,
P.O. Box 1450, Alexandria, Virginia
22313-1450



Michael R. Hull
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AMENDMENT IN RESPONSE TO NON-FINAL OFFICE ACTION

MS Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Dear Commissioner:

Please enter the following amendment in response to the office action mailed
on August 23, 2004.

**A listing of the claims and a complete listing of the claims begins on page 2
of this paper.**

Remarks/Arguments begin on page 9 of this paper.